

Search Notes

Application/Control No.

10/737,394

Examiner

W. David Coleman

Applicant(s)/Patent under
Reexamination

CHOI ET AL.

Art Unit

2823

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 438 | 795 | 3/31/2005 | WDC |
| 118 | 725 | 3/31/2005 | WDC |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 438 | 795 | 3/31/2005 | WDC |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|--|-----------|------|
| EAST 2.0.1, Applicants claim a heated stage wherein the substrate can be lifted away from the stage to change the temp. to for | 3/31/2005 | WDC |
| films at different temperatures all in one chamber. | 3/31/2005 | WDC |
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